What is claimed is:

1. An LSI inspection method, comprising:

a first step of identifying, after a front-end process is completed, a chip having a defect among all chips formed on a wafer and determining a type of defect for each defect that the identified chip has, on the basis of inspection data obtained by inspecting the wafer for a defect by means of a defect inspection apparatus after processing is performed in each of predetermined process steps among a plurality of process steps in the front-end process;

a second step of judging, for each chip identified in said first step, whether the chip is a non-conforming article or not according to non-conforming article judgment criteria corresponding to the type of defect for each defect that the chip has and obtaining position information within a surface of the wafer of a chip judged as being a non-conforming article, the non-conforming article judgment criteria for each predetermined type of defect being preset on the basis of design data of the wafer, according to which criteria whether a chip formed on the wafer is a non-conforming article or not is judged;

a third step of transmitting the position information within the surface of the wafer of each chip judged as being a non-conforming article in said second step to a test apparatus that tests an electric property of each chip formed on the wafer; and

a fourth step of not running a test on a chip identified on the basis of the position information transmitted in said third step and running the test on chips other than the identified chip, by means of said test apparatus.

- 2. The LSI inspection method according to Claim 1, wherein the non-conforming article judgment criteria for particular types of defects include criteria according to which a defect that causes a malfunction is judged, and criteria according to which a potential defect is judged.
- 3. A defect inspection data analysis apparatus, comprising:
- a first storage means to store inspection data obtained by inspecting a wafer for a defect by means of a defect inspection apparatus after processing is performed in each of predetermined process steps among a plurality of process steps in a front-end process;
- a second storage means to store non-conforming article judgment criteria, which are set for each predetermined type of defect on the basis of design data of the wafer, and according to which whether a chip formed on the wafer is a non-conforming article or not is judged;
- a defective chip identifying means to identify, after the front-end process is completed, a chip having a defect among all chips formed on the wafer and to determine a type

of defect for each defect that the identified chip has, on the basis of the inspection data stored in said first storage means;

a non-conforming chip judging means to read out, from said second storage means and for each chip identified by said defective chip identifying means, the non-conforming article judgment criteria corresponding to the type of defect for each defect that the chip has, then to judge whether the chip is a non-conforming article or not according to the read out non-conforming article judgment criteria, and to obtain position information within a surface of the wafer of a chip judged as being a non-conforming article; and

a third storage means to store the position information within the surface of the wafer of each chip judged as being a non-conforming article by said non-conforming chip judging means.

- 4. The defect inspection data analysis apparatus according to Claim 3, further comprising:
- a transmission means to transmit the position information stored in said third storage means to a test apparatus that tests an electric property of each chip formed on the wafer.
- 5. The defect inspection data analysis apparatus according to Claim 3 or 4, wherein the non-conforming

article judgment criteria for particular types of defects include criteria according to which a defect that causes a malfunction is judged, and criteria according to which a potential defect is judged.